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Dated: March 8, 2007

Docket No.: REGIM 3.3-089

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Richard J. Botos)

In re Patent Application of: Feltin et al.

Application No.: 10/573,463

Group Art Unit: 2812

Filed: December 1, 2006

Examiner: Not Assigned

For: METHOD OF PRODUCING SELF-

SUPPORTING SUBSTRATES COMPRISING

III-NITRIDES BY MEANS OF

HETEROEPITAXY ON A SACRIFICIAL

LAYER

MS Amendment Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT

Dear Sir:

It is respectfully requested that the references listed on the enclosed form be made of record and considered with respect to the above-referenced U.S. patent application. A copy of each non-US reference is enclosed. Submission of the present Information Disclosure Statement should not be taken as admission that the cited references are legally available prior art or that the same are pertinent or material.

In the event that any fee is due in connection with the present Information Disclosure Statement, the Commissioner is hereby authorized to charge the same to our Deposit Account No. 12-1095.

Dated: March 8, 2007

Respectfully submitted

Richard J. Botos

Registration No.: 32,016 LERNER, DAVID, LITTENBERG,

KRUMHOLZ & MENTLIK, LLP 600 South Avenue West

Westfield, New Jersey

(908) 654-5000

Attorney for Applicant

LD-458\



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Complete if Known Substitute for form 1449/PTO Application Number 10/573,463-Conf. #9267 INFORMATION DISCLOSURE Filing Date December 1, 2006 STATEMENT BY APPLICANT First Named Inventor Eric Pascal Feltin Art Unit 2812 (Use as many sheets as necessary) Examiner Name Not Yet Assigned **REGIM 3.3-089** 1 Sheet 1 of Attorney Docket Number

U.S. PATENT DOCUMENTS						
Examiner Initials*	Cite No.1	Document Number Number-Kind Code ² (<i>if known</i>)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	

FOREIGN PATENT DOCUMENTS							
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NON PATENT LITERATURE DOCUMENTS						
Examiner Initials	Cite No.1	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.				
	CA	Beaumont B., Vennegues P., Gibart P., "Epitaxial Overgrowth of GaN", Phys. Stat. sol. (b) 227, No. 1, pgs. 1-43, 2001.				
	СВ	Lahreche, Vennegues, Beaumont and Gibart, "Growth of high-quality GaN by low pressure metal-organic vapor phase epitaxy (LP-MOVPE) from 3D islands and lateral overgrowth", Journal of Crystal Growth 205, 245 (1999).				
	СС	Mathis et al., "Modeling of threading dislocation reduction in growing GaN layers", Journal of Crystal Growth, 231, pgs 371-390, (2001).				

^{*}EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

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